

## WAVELENGTH DIVISION MULTIPLEXING AND DE-MULTIPLEXING SYSTEM

Application:

Confirmation:

8874

Applicant(s):

John Tsai

Docket Number:

60617.300901

**Group Art Unit:** 

2874

Examiner:

(Unassigned)

search string:

(5726805).pn.

## **US Patent Documents**

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

|   | linitl | Citation<br>No. | Patent Number | Date       | Bar Code                              | Patentee       | Class | Subclass |
|---|--------|-----------------|---------------|------------|---------------------------------------|----------------|-------|----------|
| 1 | RC     | P01             | 5726805       | 1998-03-10 | 1   1   1   1   1   1   1   1   1   1 | Kaushik et al. | 359   | 589      |

## Remarks

(Remarks are not for responding to an office action.)

The listed reference was cited in an International Search Report (ISR) in the prosecution of an indirectly related Patent Cooperation Treaty (PCT) application. We feel that this reference is relevant but not determinative in the present case because it teaches a filter through which light passes perpendicular to the plane. Whereas, the present application teaches a filter through which light passes coplanarly. Although similar materials are used, and there thus is superficial similarity in the Kaushik reference and the present application, the types of filters produced, the problems encountered in construction, and the dimensions within the resulting filters are different due to the

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different manner of use of the respective filters.

## **Signature**

| Examiner Name               | Date   |
|-----------------------------|--------|
| Michelle R. Connelly-Cushwa | 9/8/03 |